



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of: **Koji NOZAKI et al.**

Art Unit: **1795**

Application Number: **10/623,679**

Examiner: **Amanda C. Walke**

Filed: **July 22, 2003**

Confirmation Number: **5083**

For: **RESIST PATTERN THICKENING MATERIAL, RESIST PATTERN AND  
PROCESS FOR FORMING THE SAME, AND SEMICONDUCTOR DEVICE  
AND PROCESS FOR MANUFACTURING THE SAME**

Attorney Docket Number: **030891**

Customer Number: **38834**

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

November 26, 2008

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated May 30, 2008 for three months from August 30, 2008 to November 30, 2008 (a two month extension of time was paid on October 30, 2008).

Attached please find our payment including the amount of \$620.00 for the cost of the extension of time. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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